

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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10/549621

In re application of:

Dirk BREIDT *et al.*

Serial No: TBA

Filed: September 20, 2005

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)
) Group Art No. TBA

)
) Examiner: TBA

)
) Docket No. 000475.00012

For: Body Having A Smooth Diamond Layer,
Device And Method Therefor

INFORMATION DISCLOSURE STATEMENT

Commissioner of Patents
U.S. Patent and Trademark Office
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Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir:

Pursuant to 37 C.F.R. §1.56 and in compliance with 37 C.F.R. §1.97, Applicants submit herewith one Form PTO-1449 identifying information for consideration by the Examiner.

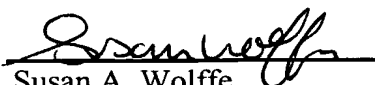
Copies of the cited documents were provided with the International Search Report for the corresponding PCT application.

If the Patent and Trademark Office determines that a fee is required, please charge our Deposit Account No. 19-0733.

Respectfully submitted,

BANNER & WITCOFF, LTD.

Date: 9/20/05

By: 
Susan A. Wolffe
Registration No. 33,568

SAW/sdm

USPTO Form 1449 U.S. Department of Commerce Patent and Trademark Office INFORMATION DISCLOSURE CITATION Sheet 1 of 1		Attorney Docket No. 10/549621 000475.00012 Applicant(s): Dirk BREIDT et al Filing Date: September 20, 2005 Group: TBA				
U.S. PATENT DOCUMENTS						
Examiner Initial	Patent No.	Date	Name	Class	Subclass	Filing Date (if appropriate)
	US 5 567 522 A	22 October 1996	TAKAHASHI, T et al.			
FOREIGN PATENT DOCUMENTS						
Examiner Initial	Document No.	Date	Country	Class	Subclass	Translation
	DE 199 22 665 A	23 November 2000	Germany			YES NO
	WO 01/18284 A	15 March 2001	PCT			
OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, etc.)						
	ALI et al.: "Promoting secondary nucleation using methane modulations during diamond chemical vapor deposition to produce smoother, harder, and better quality films", J. MATER. RES. (USA) JOURNAL OF MATERIALS RESEARCH, Feb 2003, Vol. 18, NO. 2, pages 296-304, XP009034569.					
	ALI et al.: "Deposition of polycrystalline diamond films using conventional and time-modulated CVD processes", THIN SOLID FILMS, vol. 420-421, December 2, 2002, pages 155-160, XP004397837					
	FAN et al.: "Novel time-modulated chemical vapor deposition process for growing diamond films", J. MATER. RES. (USA) JOURNAL OF MATERIALS RESEARCH, July 2002, vol. 17, no. 7, pages 1563-1566, XP009034570.					
	LEE et al.: "Cyclic technique for the enhancement of highly oriented diamond film growth", THIN SOLID FILMS, vol. 303, no. 1-2, July 15, 1997, pages 264-268, XP004087644.					
	KOMAROV et al.: "Self-Limiting Diamond Growth from Alternating CFX and H Fluxes:", DIAMOND AND RELATED MATERIALS, vol. 7, no. 8, August 1, 1998, pages 1087-1094, XP000668682.					
	CHEN et al.: "Growth of Highly Transparent Nanocrystalline Diamond Films and a Spectroscopic Study of the Growth", JOURNAL OF APPLIED PHYSICS, vol. 89, no. 1, January 1, 2001, pages 753-759, XP001053812.					
	JIANG et al.: "Synthesis and structural study of nano/micro diamond overlayer films", JOURNAL OF CRYSTAL GROWTH, vol. 242, no. 3-4, July 2002, pages 362-366, XP004368868.					
	ALI et al.: "Nanocrystalline diamond films deposited using a new growth regime", MATER. SCI. TECHNOL. (UK), MATERIALS SCIENCE AND TECHNOLOGY, July 2003, vol. 19, no. 7, July 2003, pages 987-990, XP009034515.					
	ALI et al.: "Implementation of the time-modulated process to produce diamond films using microwave-plasma and hot-filament CVD systems", VACUUM, (UK) July 25, 2003, vol. 71, no.4, pages 445-450, XP002290488.					
EXAMINER				DATE CONSIDERED		
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.						